

Electric Field Density Distribution for Cochlear Implant Electrodes

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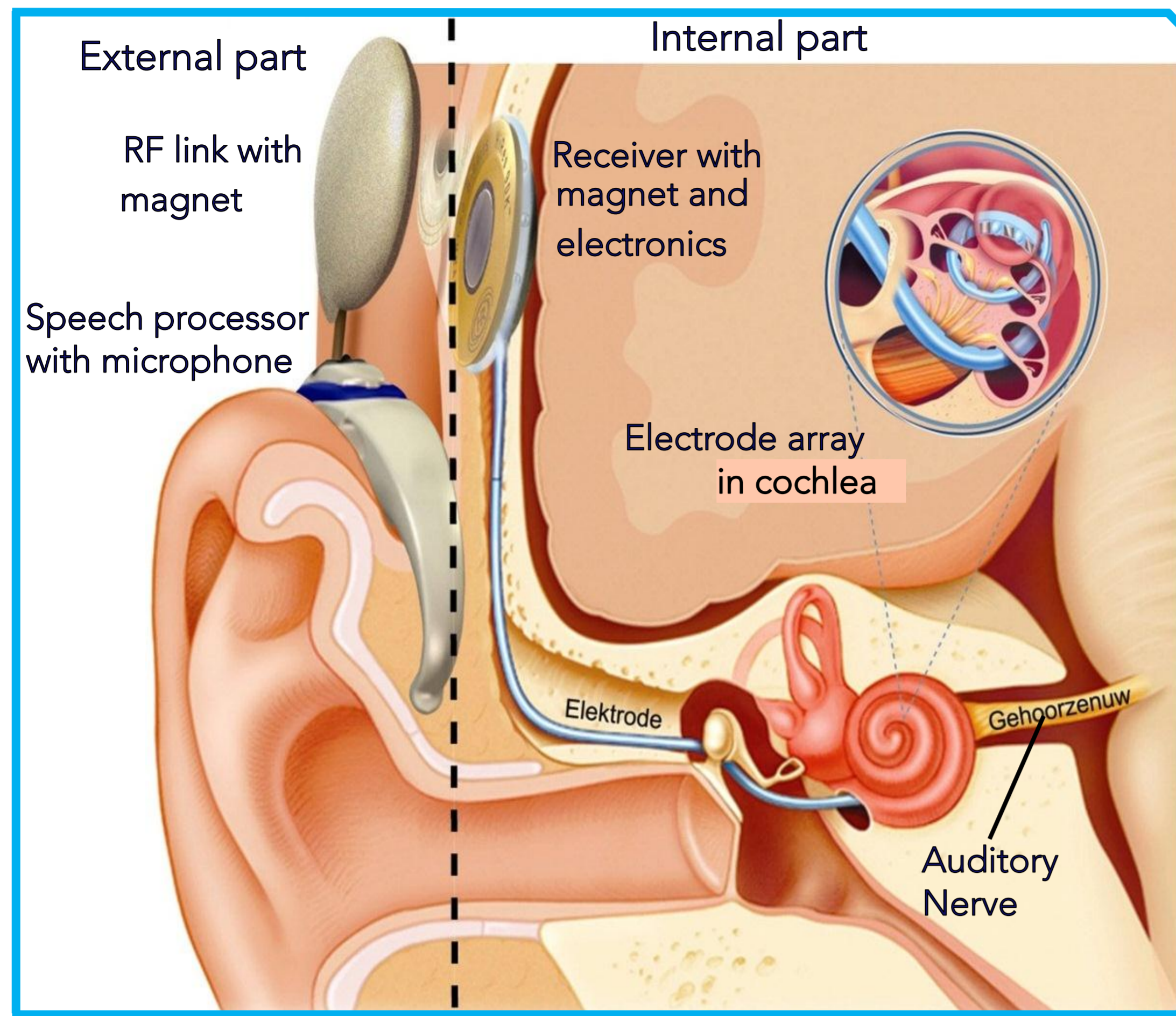


Figure 1: Sketch of a human ear with the implant



Results:

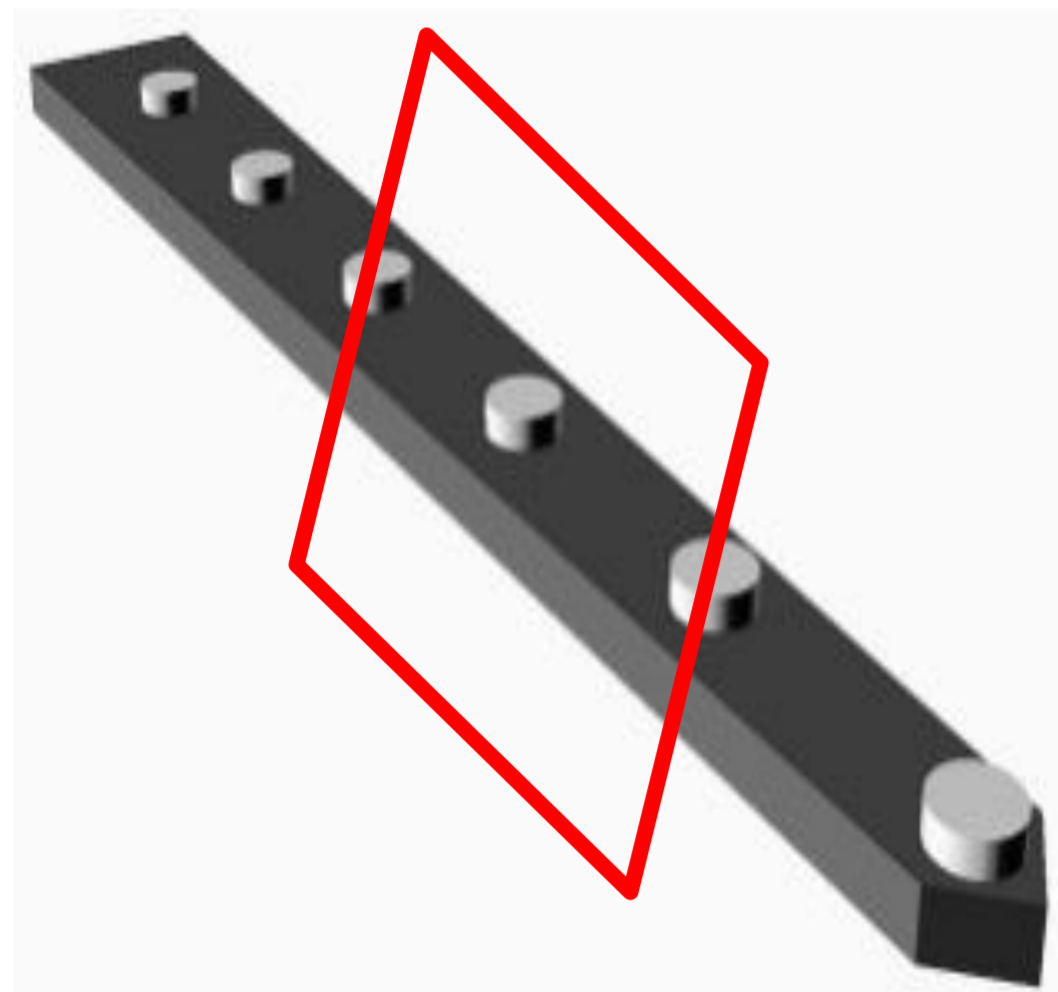
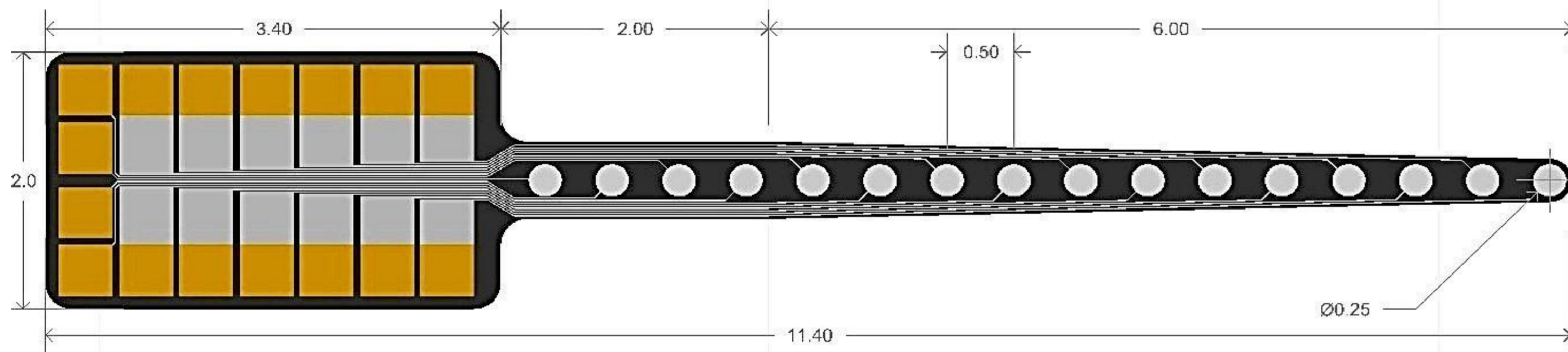
The AC/DC module from Comsol 4.2a has been used with a parametric sweep to switch between the different configurations. The center electrode is stimulated with a potential of 544 mV [4] and the bottom boundary is considered as a ground. The fluid in the cochlea is Perilymph, a fluid with high K^+ and low Na^+ concentration [3]. A cut line is taken at $30 \mu\text{m}$ from the surface of the substrate along the x-axis.

Introduction:

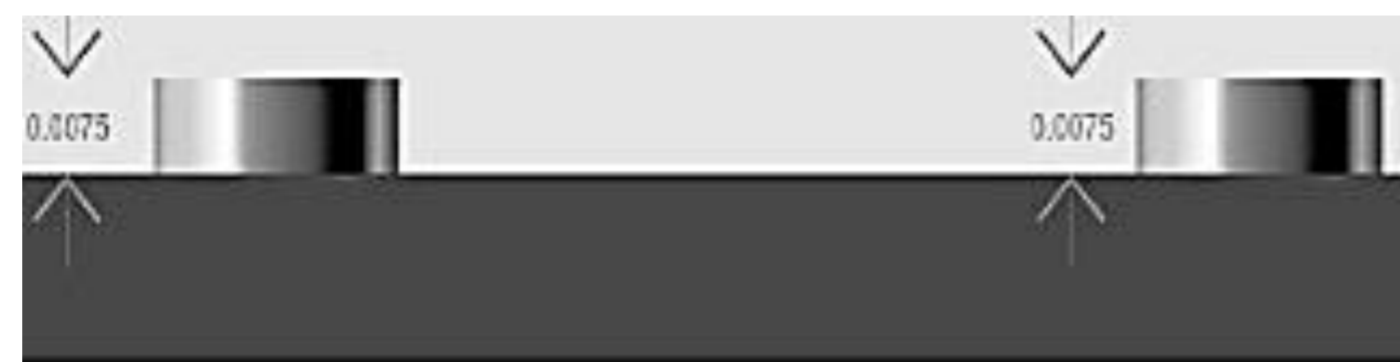
Cochlear Implants (CIs) are implantable devices that bypass the non-functional inner ear and directly stimulate the auditory nerve with electric currents, thus enabling deaf people to experience sound again.

Geometry:

The basic design of CI electrode array consists of an Silicon substrate with titanium nitride (TiN) stimulation sites [1] coated with Parylene HT (Figure 2). Three different electrode configurations are proposed: Protruded, Planar and Embedded (Figure 3). The goal is to minimize the potential, but it has to be high enough to trigger an action potential. Figure 4 shows the non-scaled geometry of the model.



Stimulation sites with protruded design.



Stimulation sites with planar design.



Stimulation sites with embedded design.



Figure 2: Design of the stiff probe

Titanium Nitride Electrodes
Silicon Base
Parylene
Perilymph (Fluid in Cochlea)

Figure 3: The three proposed configurations

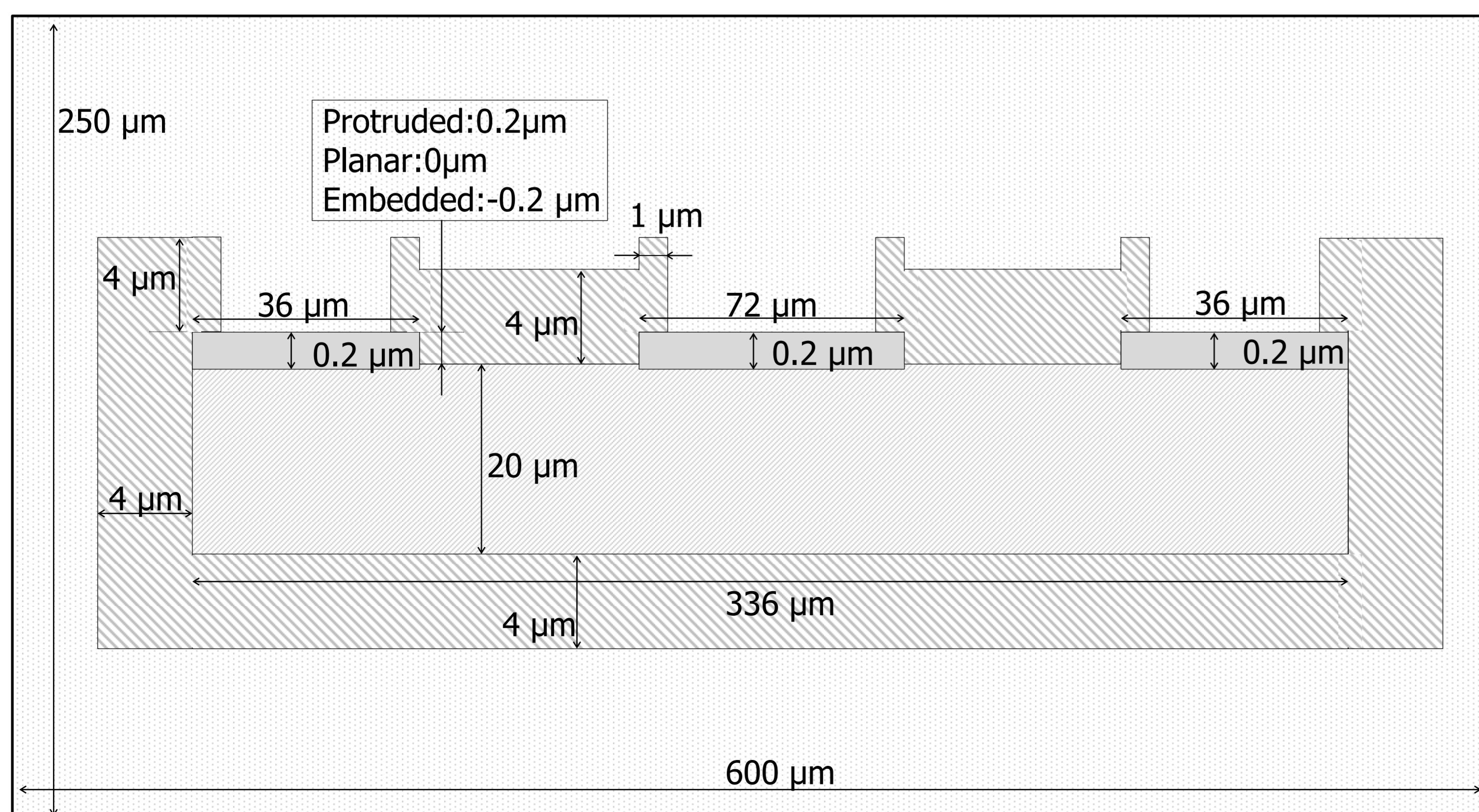


Figure 4: Geometry of the simulated model of a cross-section of an electrode array (the red parallelogram of Figure 2) inside a cochlea. The cochlea is considered as a rectangle here [2].

ht(3)=0.2 Surface: Electric field norm (V/m)
Contour: Electric potential (V)

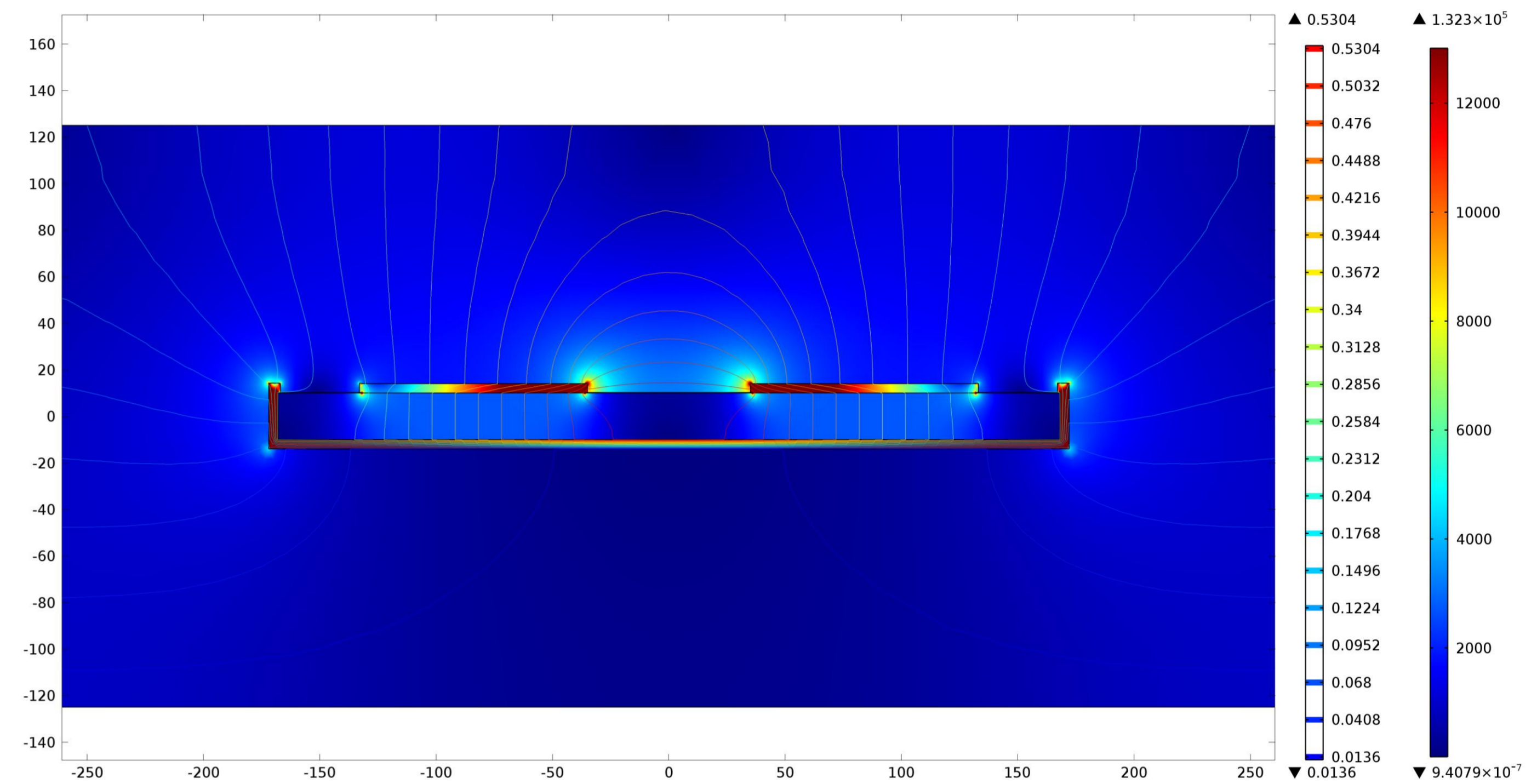


Figure 5: Electric Field Distribution of the model for the Protruded design

Line Graph: Electric potential (V)

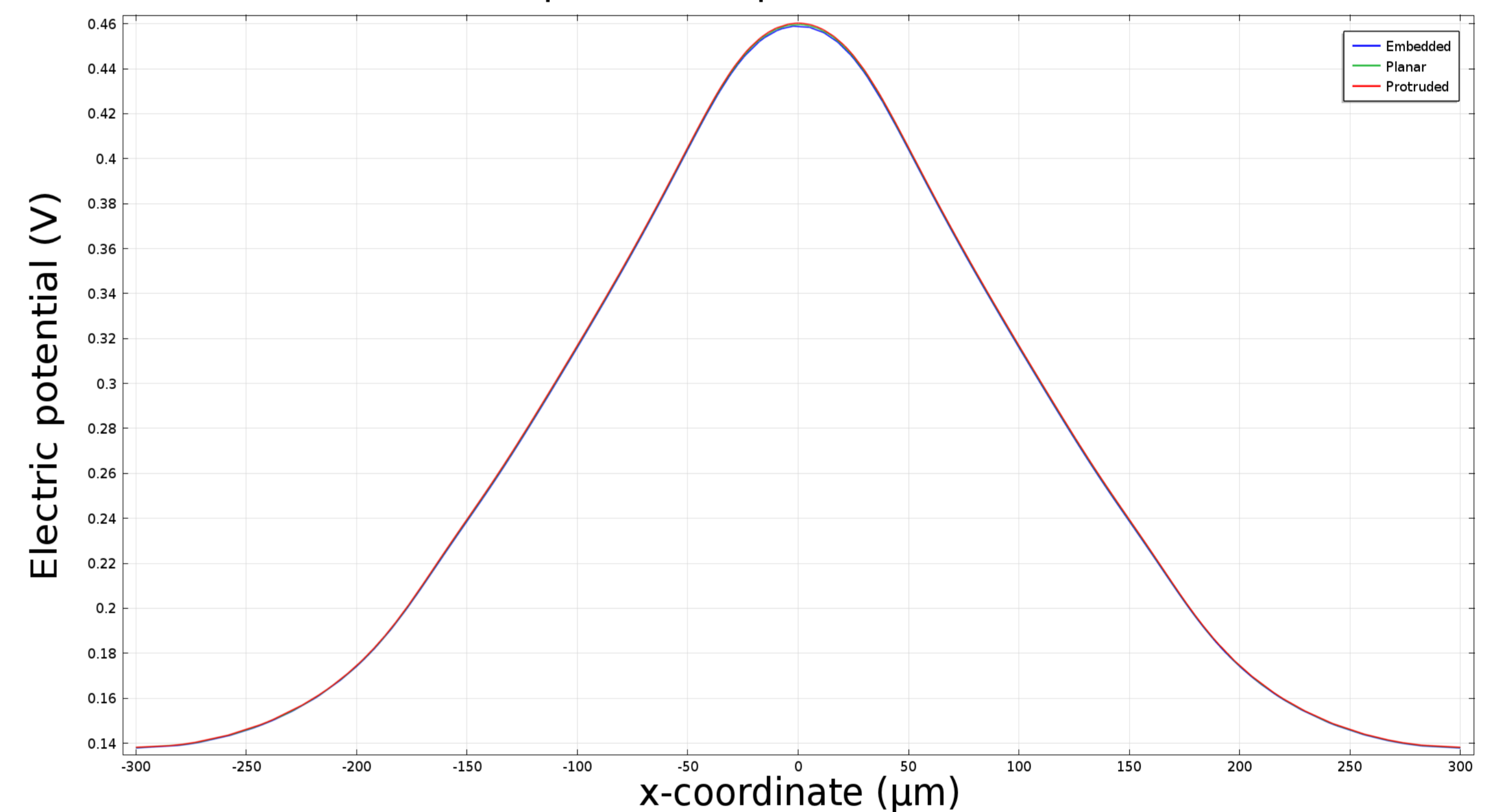


Figure 6: Potential at $30 \mu\text{m}$ from the surface for the three different designs

Conclusions:

Because of the little difference in shape of the electric field distribution (Figure 6), the protruded design has been chosen from fabrication point of view.

References:

- [1] N. S. Lawand, P. J. French, J. J. Briaire, J. H. M Frijns, "Silicon probes for cochlear auditory nerve stimulation and measurement," *Advanced Materials Research*, Vol. 254, pp. 82 – 85, (2011).
- [2] Clark, G. (2003). *Cochlear Implants, Fundamentals and Applications*. Melbourne: Springer Science+Business Media, Inc.
- [3] Rienen, U. v., Flehr, J., Schreiber, U., Schulze, S., Gimsa, U., Baumann, W., et al. (2005). *Electro-Quasistatic Simulations in Bio-Systems Engineering and Medical Engineering*. *Advances in Radio Science* 3, 39-49.
- [4] Tognola, G., Pesatori, A., Norgia, M., Parazzini, M., Rienzo, L. D., Ravazzani, P., et al. (february 2007). *Numerical Modeling and Experimental Measurements of the Electric Potential Generated by Cochlear Implants in Physiological Tissues*. *Instrumentation and Measurement, IEEE Transactions on*, Volume:56 Issue:1, 187-193.